



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#8/Amend B
Amend
7/23/02

Application Serial No. 09/879,335
Filing Date June 11, 2001
Inventor Vishnu K. Agarwal, et al
Assignee Micron Technology, Inc.
Group Art Unit 2813
Examiner Y. Huynh
Attorney's Docket No. MI22-1568
Title: Capacitor Forming Methods

RECEIVED
JUL 11 2002
TECHNOLOGY CENTER 2800

RESPONSE TO APRIL 1, 2002 OFFICE ACTION

To: Box Non Fee Amendment
Art Unit 2813
Assistant Commissioner for Patents
Washington, D.C. 20231

From: James E. Lake (Tel. 509-624-4276; Fax 509-838-3424)
Wells, St. John, Roberts, Gregory & Matkin P.S.
601 W. First Avenue, Suite 1300
Spokane, WA 99201-3828

AMENDMENTS

In the Specification

Please replace the title with the following clean replacement title in accordance with
37 C.F.R. § 1.121(b)(1)(ii):

✓--Capacitor Forming Methods--

Please replace the paragraph beginning at line 4 of page 1 with the following clean
replacement paragraph in accordance with 37 C.F.R. § 1.121(b)(1)(ii):

--This patent resulted from a continuation-in-part application of U.S. Patent
Application Serial No. 09/710,546, filed on November 8, 2000, ^{now pending} entitled "Semiconductor
Processing Method" and naming Kunal R. Parekh and Randhir P.S. Thakur as inventors,
which application is a continuation application of ^{US SER. NO. 08/994,054 now} U.S. Patent No. 6,165,833, filed on
December 19, 1997, each of which are herein incorporated by reference.--

61

EV077329570

3